

Solid-State ^{29}Si NMR and Infrared Studies of the Reactions of Mono- and Polyfunctional Silanes with Zeolite Y Surfaces

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Abstract: The combined use of ^{29}Si magic-angle spinning NMR spectroscopy and in situ infrared techniques allows for the first time the determination of the intrazeolitic reaction products and details of the interaction of various silanes with zeolitic protons in HY zeolite. Alkoxy groups at Me_3SiOMe and MeSi(OMe)_3 are readily lost to form hydroxy groups and then siloxane bridges to the zeolite framework. At elevated temperatures, alkyl groups are also split off from the silane, and more highly substituted siloxane species are generated which are anchored to the framework via two siloxane bridges. Chloro groups at trimethylchlorosilane are rapidly hydrolyzed by the surface hydroxy groups, and the resulting products follow the reaction pattern of the alkoxy silanes. Hexamethyldisilazane and trimethylsilane do not react irreversibly with the zeolite hydroxyls at 295 K but are as reactive as other silanes at 473 K. A major product with these silanes shows a unique NMR shift at about +40 ppm and is assigned to a Lewis acid or strongly hydrogen-bonded association of the anchored silicon species with a framework metal. Most of the reactions are more complex than those of halosilanes with the terminal hydroxyls of silica, indicating the extreme reactivity of bridged hydroxyl groups in zeolites.

The chemical modification of zeolites has attracted considerable attention since these crystalline porous materials were introduced several decades ago. Ion exchange by transition metals and ammonium ions plays a major role to control catalytic and acidic properties. The complex zeolite structure is, however, by far not limited to modifications by these techniques, and recent work has focused on tailoring the hydrophobicity, adjusting the pore sizes, or specifically poisoning certain catalytic functions of the zeolite surface.

The intention of this study is to explore the possibility of "anchoring" certain molecules to the internal surface of the zeolite pore system. If reactions of this kind could be controlled, a general means would be available for the synthesis of fixed ligands, acids, or other functional groups in the pore system. Silanes represent a well-known class of reagents for the modification of oxide surfaces, and a number of studies deal with surface reactions of silanes with zeolites.¹⁻¹⁴

While the reactivity of polyfunctional silanes with zeolites has been established, only limited attempts have been undertaken to characterize the systems obtained by the various treatments. In this study, a combination of solid-state magic-angle spinning NMR (MAS NMR) and in situ infrared spectroscopy has been employed to elucidate the chemistry of silanes in the pore system of acid zeolites. MAS NMR has recently been used for detailed studies on related reactions of silanes with the terminal hydroxyls of amorphous silica.¹⁵⁻²³

Infrared spectroscopy as a complimentary technique contributes to the understanding of acid-base chemistry of oxide surfaces and has been applied to differentiate between the reactivity of geminal and single silica hydroxyls toward hexamethyldisilazane and methyltrimethoxysilane.^{24,25}

Experimental Section

1. Materials. Trimethylmethoxysilane, methyltrimethoxysilane, trimethylchlorosilane, and hexamethyldisilazane (Strem Chemicals) were stored over sieve 4A without further purification. Gaseous trimethylsilane (Petrarch Systems) was used without purification. NH_4Y zeolite with the composition $\text{Na}_8(\text{NH}_4)_{47}\text{Al}_{55}\text{Si}_{137}\text{O}_{384}\cdot n\text{H}_2\text{O}$ was obtained from Linde (LZ-Y62). Prior to use, the ammonium form of the zeolite was degassed by heating at a rate of 2 K/min to 670 K and maintained at 670 K for 12 h under 10^{-5} Torr to yield the dry acid form (HY).

2. Methods. Samples for solid-state NMR experiments were prepared as follows. Batches of dry HY (ca. 500 mg) were weighed into a small

quartz holder, introduced into a tubular quartz reactor, and evacuated at a greaseless vacuum line (10^{-5} Torr) for 30 min. A degassed and frozen vial containing the silane was allowed to warm to 273 K and dosed manometrically onto the zeolite. After equilibrating for 120 min at 295 K, the sample was evacuated for 30 min, and weight changes were recorded in the drybox. The calculated loading (molecules of silanes per superpage, X/SC) is listed for each sample in the corresponding figure caption, based on equivalents of physisorbed silane. Heat treatments were done in the same reactor under vacuum, or under the vapor pressure of the silane, with a heating rate of 1 K/min. With trimethylsilane, an excess was dosed on the zeolite at a pressure of 50 Torr.

The ^{29}Si NMR spectra were obtained at 59.6 MHz on a Bruker CXP-300 instrument. Andrews type rotors were filled with ca. 200 mg of sample in the drybox and introduced into the NMR probe in a glovebag under flowing nitrogen. All spectra were obtained with magic-angle spinning (MAS) and cross-polarization (CP). The rotor was driven by dry nitrogen gas to obtain spinning rates between 2 and 4 kHz.

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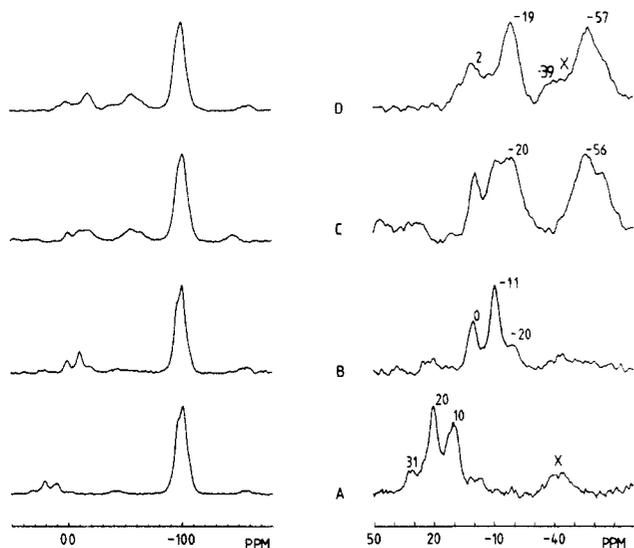


Figure 1. ^{29}Si CP-MAS NMR spectra of trimethylmethoxysilane chemisorbed on dehydrated HY zeolite. X denotes spinning sidebands of the zeolite framework resonances. (A) Equilibrated for 120 min at 295 K, degassed for 30 min (2.4 equiv per supercage, 2.4/SC); (B) degassed at 403 K for 180 min; (C) degassed at 523 K for 12 h; and (D) equilibrated at 473 K for 120 min, degassed for 30 min (2.4/SC).

Previously reported studies of structurally similar species on derivatized silica have defined conditions which yield quantitative spectra;²¹ 10 ms cross-polarization, followed by 20 to 60 ms ^1H decoupling, was used for all spectra reported here. 1000 to 8000 scans were acquired to obtain adequate signal-to-noise ratio. The quantitative accuracy of this CP experiment was verified in selected samples by Bloch decay experiments, employing a $7\ \mu\text{s}$ 90° pulse and 10 s recycle delay. Chemical shifts were referenced to Me_4Si , using external hexamethyltrisiloxane in CDCl_3 (-9.2 ppm) as secondary reference. No significant oxidation of the silanes was observed during the NMR experiments.

In situ infrared experiments were done with self-supporting zeolite wafers ($5\ \text{mg}/\text{cm}^2$) compacted at $100\ \text{kg}/\text{cm}^2$, in a controlled-atmosphere cell with CaF_2 windows connected to a Nicolet 5DXB FT-IR spectrometer. Sample treatment was similar to that of the NMR samples, with the exception of shorter temperature cycles.

In order to facilitate a comparison of relative amounts of surface silyl species, the relative intensities of all ^{29}Si resonances observed downfield from the bulk zeolite are given in mole percentages. This is based upon the assumption that negligible amounts of the silanes have been oxidized to $\text{Si}(\text{OX})_4$ species which would be obscured by the bulk zeolite resonance.

Results and Discussion

Trimethylmethoxysilane. ^{29}Si MAS NMR spectra of HY loaded with Me_3SiOMe vapor are shown in Figure 1, A–D left. The major resonances are due to silicon in the zeolite framework having one Al and three Si neighbors at -98 ppm and having four Si neighbors at -101.5 ppm. Throughout this study, the chemical shifts of these resonances are unchanged. Slight variations in the relative intensities of these resonances are observed and reflect differences in the spin–lattice relaxation times of the framework Si sites in these dehydrated zeolites. The region of interest in this work spans the chemical shifts of silanes and siloxanes and is expanded in Figures 1, A–D right.

The ^{29}Si NMR chemical shift is a powerful tool for identifying various surface sites. Of interest in this work are the chemical shifts of silicon bonded to Me, OMe, OH, and Cl groups and bonded to the silica or aluminosilicate surface by a bridging oxygen, as in a disiloxane (here denoted OSi). From the large body of relevant data available in the literature^{26,27,29} chemical

Table I. ^{29}Si Chemical Shifts of Substituted Methylsilanes

molecule or site	shift ^a	molecule or site	shift ^a
Monosubstituted			
Me_3SiCl	+30 ^b	Me_3SiOSi	+8 ^d
Me_3SiOMe	+18 ^b	Me_3SiH	-16 ^b
Me_3SiOH	+17 ^c		
Disubstituted			
Me_2SiCl_2	+32 ^b	$\text{Me}_2\text{Si}(\text{OH})\text{OSi}$	-12 ^d
$\text{Me}_2\text{Si}(\text{Cl})\text{OSi}$	+2 ^d	$\text{Me}_2\text{Si}(\text{OSi})_2$	-14 ^d
$\text{Me}_2\text{Si}(\text{OMe})_2$	-2 ^b		
Trisubstituted			
MeSiCl_3	+12 ^b	$\text{MeSi}(\text{OH})_2(\text{OSi})$	-42 ^d
$\text{MeSi}(\text{Cl})_2\text{OSi}$	-14 ^d	$\text{MeSi}(\text{OH})(\text{OSi})_2$	-52 ^d
$\text{MeSi}(\text{Cl})(\text{OSi})_2$	-38 ^d	$\text{MeSi}(\text{OMe})(\text{OSi})_2$	-58 ^c
$\text{MeSi}(\text{Cl})(\text{OH})(\text{OSi})$	-29 ^d	$\text{MeSi}(\text{OSi})_3$	-62 ^d
$\text{MeSi}(\text{OMe})_3$	-41 ^b		
Quaternary			
$\text{Si}(\text{OMe})_4$	-79 ^{b,e}	$\text{Si}(\text{OH})_3(\text{OSi})$	-83 ^{g,h}
$\text{Si}(\text{OMe})_3(\text{OSi})$	-86 ^e	$\text{Si}(\text{OH})_2(\text{OSi})_2$	-92 ^{h,i}
$\text{Si}(\text{OMe})_2(\text{OSi})_2$	-94 ^e	$\text{Si}(\text{OH})(\text{OSi})_3$	-104 ^{h,i}
$\text{Si}(\text{OMe})(\text{OSi})_3$	-104 ^e	$\text{Si}(\text{OSi})_4$	-112 ^{h,i,j}
$\text{Si}(\text{OH})_4$	-74 ^f		

^a In ppm relative to Me_4Si . ^b Table 10.1, p 313, in ref 29. ^c Predicted using additive substituent effects from data in ref 29, following the method outlined in ref 27 as further discussed in the text. ^d Reference 27. ^e Reference 31. ^f Farlee, R. D.; Concannon, T. P., unpublished work. Similar values have been reported elsewhere (ref 28 and 30). ^g Average value for disilicates. ^h Analogous sites in silicates exhibit chemical shifts covering a substantial range (ref 32) depending on the average substituent electronegativity and Si–O–Si angle (ref 28). ⁱ These are typical values for silica (ref 21 and 27). ^j Q4 sites in zeolites and tectosilicates span a considerable range and can be predicted from the number of Al neighbors and average Si–O–T (T = Si, Al) angle (ref 33).

shifts of essentially all the possible products with the species of interest in this work can be compiled (Table I). It is important to note that mono-, di-, and trisubstitution are resolved in well-defined ^{29}Si chemical shift regions.

It should be noted that it appears that a small but consistent downfield shift is observed in the solid state relative to solution. Sindorf and Maciel²⁷ report an average “solid-state ^{29}Si chemical shift” difference of +7 ppm for trimethylsilyl groups bonded to a silica surface, relative to their shift in solution. We find this value to vary between +2 and +7 ppm in the species studied here. This shift is not included in those data reported in Table I which were measured in solution.

The chemical shifts of discrete alkyl monosilicate species are not available because of their instability toward rapid condensation to higher silicates. However, one would expect that the shifts for the series $\text{Si}(\text{OH})_n(\text{OMe})_{4-n}$ would all lie between -79 ppm ($n = 0$)^{29,32} and -74 ppm ($n = 4$)^{29,31} if the substituent effects are assumed to be linearly additive.

The coverage of silicas can be calculated directly from the areas of the $\text{Si}(\text{OH})_2(\text{OSi})_2$, $\text{Si}(\text{OH})(\text{OSi})_3$, and $\text{Me}_3\text{Si}(\text{OSi})$ resonances in ^{29}Si CP-MAS spectra.^{15,17,20,21} In zeolite Y, these effects are masked by signal from the bulk zeolite and cannot be differentiated from the external surface.

If dehydrated HY zeolite is saturated with vapor of Me_3SiOMe at 295 K, three new silicon species at 31, 20, and 10 ppm are observed in the ^{29}Si MAS NMR of the zeolite (Figure 1A). The species at 20 ppm (45 mol %) can be assigned either to the starting silane (17.7 ppm in solution) or to the hydrolysis product, Me_3SiOH , which has a predicted shift of 17 ppm (see Table I). These observations, including assignments, are summarized in Table II.

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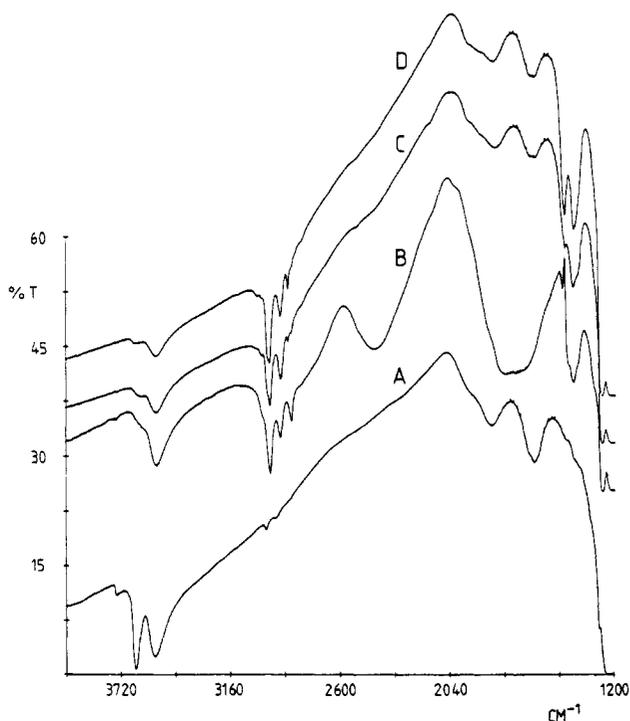
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Table II. ^{29}Si CP-MAS Resonances Observed after Adsorption of Trimethylmethoxysilane (Me_3SiOMe) on HY Zeolite

conditions	assignment	shift, ppm	mol %
vapor 295 K, 120 min, degassed 30 min	Lewis adduct	31	17
	Me_3SiOMe	20	45
	Me_3SiOSi	10	38
degassed 403 K, 180 min	$\text{Me}_2\text{Si}(\text{OMe})_2$	0	28
	$\text{Me}_2\text{Si}(\text{OMe})\text{OSi}$	-11	54
	$\text{Me}_2\text{Si}(\text{OSi})_2$	-20	18
degassed 523 K, 12 h	$\text{Me}_2\text{Si}(\text{OMe})_2$	0	55
	$\text{Me}_2\text{Si}(\text{OMe})\text{OSi}$	-11	
	$\text{Me}_2\text{Si}(\text{OSi})_2$	-20	
	$\text{MeSi}(\text{OMe})(\text{OSi})_2$	-56	
	$\text{Me}_2\text{Si}(\text{OMe})_2$	2	
vapor 473 K, 120 min, degassed 10 min	$\text{Me}_2\text{Si}(\text{OMe})_2$	2	18
	$\text{Me}_2\text{Si}(\text{OSi})_2$	-19	32
	$\text{MeSi}(\text{OMe})_2\text{OSi}$	-39	9
	$\text{MeSi}(\text{OMe})(\text{OSi})_2$	-57	41

**Figure 2.** IR spectra of wafer of HY zeolite, degassed at 670 K, loaded with Me_3SiOMe : (A) the degassed zeolite; (B) equilibrated for 10 min at 295 K, degassed for 30 min; (C) equilibrated for 60 min at 403 K, degassed for 10 min; and (D) equilibrated for 120 min at 473 K, degassed for 10 min.

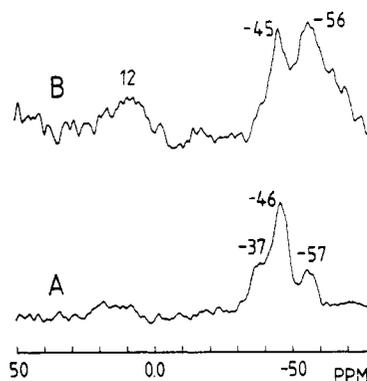
Trimethylsilyl groups bonded to the surface, Me_3SiOSi , are observed at 10 ppm (38%). The third peak at 31 ppm appears at an unusual position for oxygen-bonded silicon and will be labeled as a yet undefined Si-zeolite Lewis acid adduct (see below).

Upon degassing this material at 403 K under vacuum, striking changes occur in the ^{29}Si NMR spectrum. None of the original silanes seen between 30 and 10 ppm survive this treatment, and new resonances at 0 (28%), -11 (54%), and -20 ppm (18%) are observed (Figure 1B). These data are consistent with the generation of $\text{Me}_2\text{Si}(\text{OMe})_2$ (-2 ppm) and two products of condensation with the zeolite hydroxyls: $\text{Me}_2\text{Si}(\text{OMe})\text{OSi}$ and $\text{Me}_2\text{Si}(\text{OSi})_2$ (Table II).

Further heating at higher temperature (523 K) causes further condensation of the dimethylsiloxane species (Figure 1C).

If dehydrated HY is equilibrated with vapor of Me_3SiOMe at 473 K, more pronounced condensation is observed compared to the vacuum treatments (Figure 1D).

The IR spectrum of a self-supporting wafer of NH_4Y zeolite, degassed at 670 K for 14 h under vacuum, is shown in Figure 2A. Three well-known hydroxyl groups can be distinguished: terminal Si-OH groups at the outer surface of the zeolite crystals (3740 cm^{-1}), "supercage" SiO(H)Al hydroxyls at 3640, and "sodalite"

**Figure 3.** ^{29}Si CP-MAS NMR spectra of methyltrimethoxysilane chemisorbed on dehydrated HY zeolite: (A) equilibrated for 120 min at 295 K, degassed for 30 min (0.3/SC); and (B) degassed at 403 K for 180 min (<0.1/SC).**Table III.** ^{29}Si CP-MAS Resonances Observed after Adsorption of Methyltrimethoxysilane ($\text{MeSi}(\text{OMe})_3$) on HY Zeolite

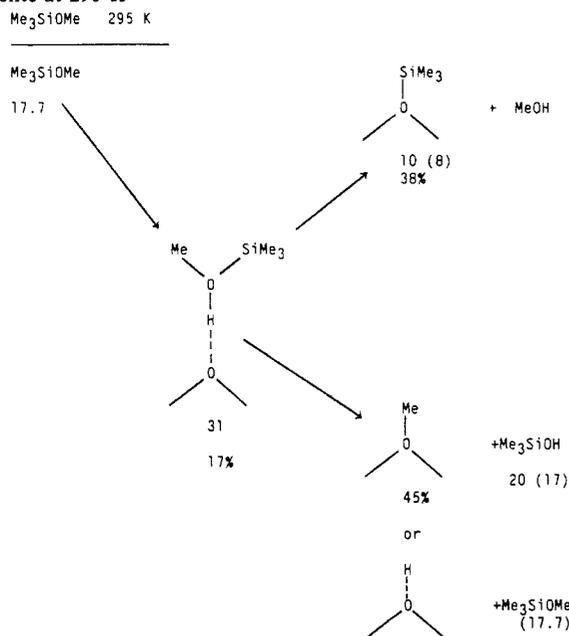
conditions	assignment	shift	mol %
vapor 295 K, 10 min, degassed 30 min	Me_3SiOMe	18	7
	Me_3SiOSi	8	7
	$\text{MeSi}(\text{OMe})_3$	-37	14
	$\text{MeSi}(\text{OMe})_2\text{OSi}$	-46	53
degassed 403 K, 180 min	$\text{MeSi}(\text{OMe})(\text{OSi})_2$	-57	19
	Me_3SiOSi	12	22
	$\text{MeSi}(\text{OMe})_2\text{OSi}$	-45	25
	$\text{MeSi}(\text{OMe})(\text{OSi})_2$	-56	53

SiO(H)Al at 3540 cm^{-1} . The latter two species, depicted as SiO(H)Al or HOZ, are bridged hydroxyls, located in different framework positions in the Si-O-Al six-rings of the faujasite structure.

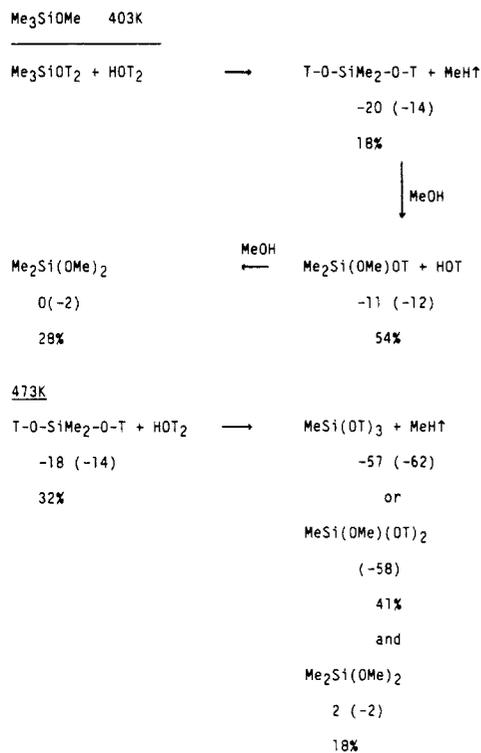
If the zeolite wafer is equilibrated with vapor of Me_3SiOMe and pumped off for 30 min, striking changes in the spectrum indicate an acid-base reaction between the zeolite hydroxyls and the silane (Figure 2B). The high-frequency supercage hydroxyls are almost entirely consumed upon chemisorption, whereas the low-frequency hydroxyls are essentially unaffected. In addition to the expected C-H stretching and bending vibrations of the silane (3000-2800 and 1480-1370 cm^{-1}), two strong broad bands are observed at 2425 and 1750 cm^{-1} . The former vibration is assigned to proton-stretching modes of protonated siloxane species, like $\text{Me}_3\text{SiOH}-\text{OT}_2$, that are protolysis products of the chemisorbed silane. The band around 1750 cm^{-1} cannot be correlated to a specific species at the present time. The spectroscopic observations and their interpretations are summarized in Scheme I.

Treatment of the zeolite wafer with silane at 403 K for 1 h results in dramatic changes (Figure 2C). In addition to the supercage hydroxyls, a large fraction of the previously inaccessible low-frequency hydroxyls are also consumed. The broad bands at 1750 and 2425 cm^{-1} are destroyed, and changes in the C-H stretch intensities at 2860 cm^{-1} indicate the loss of certain species. Further treatment with silane vapor at elevated temperature (2 h at 473 K) causes continued consumption of the hydroxyl groups and formation of a new species at 1455 cm^{-1} (Figure 2D). This mode is assigned to the methoxy group of the trisubstituted, framework anchored siloxane $\text{MeSi}(\text{OMe})(\text{OSi})_2$ which is observed in the corresponding NMR experiment (Figure 1D).

Heating at elevated temperatures removes the unstable products and intermediates from the zeolite. None of the previous species remain, and the NMR data allow the conclusion that di- and trisubstituted siloxanes are formed (Scheme II). Additional protons are delivered from nonaccessible sites into the supercage, as indicated by IR spectroscopy. At this stage, methyl groups are split off from the silane. This behavior is unknown with silica supports and points to the strong acidity of the zeolite. One reaction path proposed is the acid-catalyzed methyl-group substitution at the framework bonded monosiloxane (Scheme II). At higher degassing temperatures (523 K), the higher condensation

Scheme I. Proposed Reaction Pathways for Me_3SiOMe in HY Zeolite at 295 K^a


^a Indicated values are the ²⁹Si chemical shift data, compared to expected values (Table I) in parentheses. Percent values refer to the relative amounts of silane species as detected by ²⁹Si MAS-NMR.

Scheme II. Proposed Reaction Pathways for Me_3SiOMe in HY Zeolite at Elevated Temperatures


product $\text{Me}_2\text{Si(OSi)}_2$ becomes more pronounced, and an additional *trisubstituted* species MeSi(OSi)_3 grows in.

Methyltrimethoxysilane. At least four new silicon species are observed in the ²⁹Si NMR of HY upon equilibration with MeSi(OMe)_3 at 295 K. New peaks appear at 18, 8, -37, -46, and -57 ppm (Figure 3A). These observations, with corresponding assignments, are summarized in Table III and in Scheme III.

The major component of the spectrum at -46 ppm (53%) can be assigned to the monosubstituted starting silane, $\text{MeSi(OMe)}_2\text{OSi}$. The resonance at -57 ppm is due to disubstituted product, MeSi(OMe)(OSi)_2 .

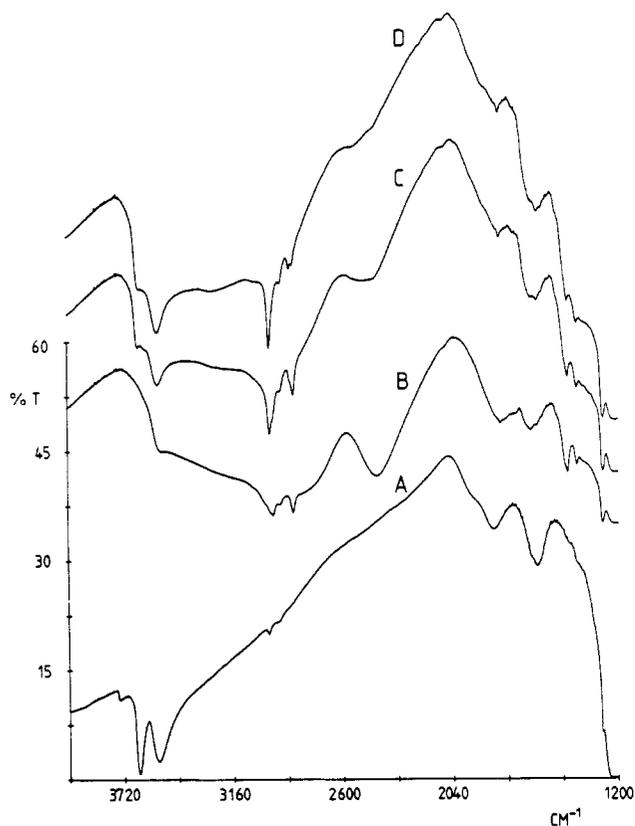
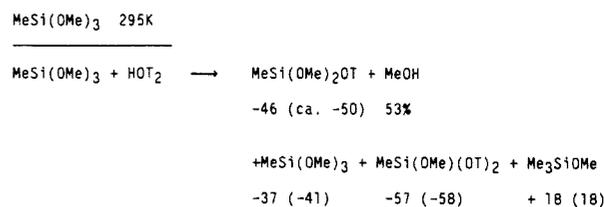


Figure 4. IR spectra of a wafer of HY zeolite, degassed at 670 K, loaded with MeSi(OMe)_3 : (A) the degassed zeolite; (B) equilibrated for 10 min at 295 K, degassed for 30 min; (C) equilibrated for 60 min at 403 K, degassed for 10 min; and (D) equilibrated for 120 min at 473 K, degassed for 10 min.

Scheme III. Proposed Reaction Pathways for MeSi(OMe)_3 in HY Zeolite at 295 K


Upon degassing this material at 403 K under vacuum, a gradual shift of intensities in favor of the higher condensation products is observed (Figure 3B). The heat treatment transforms the major fraction of the silane into methoxymethylsilyl groups, MeSi(OMe)(OSi)_2 , at -56 ppm (53%), in addition to $\text{MeSi(OMe)}_2\text{(OSi)}$.

Saturation of the dehydrated zeolite wafer (Figure 4A) with MeSi(OMe)_3 at 295 K causes dramatic changes in the IR spectrum. An extremely strong and broad absorption appears between 3600 and 2600 cm^{-1} (Figure 4B). The only structure visible on this absorption is a shoulder at 3525 (sodalite hydroxyl) and the C-H stretch bands at 3000–2800 cm^{-1} . The broad absorption is assigned to a convolution of free hydroxyl and intermolecular bonded hydroxyl vibrations, most likely due to interactions of the byproduct MeOH with the zeolite hydroxyls. At 2425 cm^{-1} , a strong, symmetric absorption appears that is assigned to weaker hydroxyl bonds with the starting material, as observed with Me_3SiOMe (Figure 2).

It should be noted that hydrolyzable groups at silanes do not always lead to a complete consumption of zeolite hydroxyls. At elevated temperatures, only the monomethoxysilane Me_3SiOMe shows an increasing tendency to destroy the unaccessible "sodalite" protons, whereas Me_3SiCl and MeSi(OMe)_3 leave these groups essentially unaffected.

Table IV. ^{29}Si CP-MAS Resonances Observed after Adsorption of Trimethylchlorosilane (Me_3SiCl) on HY and NaY Zeolites

conditions	assignment	shift	mol %
HY			
vapor 295 K, 120 min, degassed 30 min	Lewis adduct	40	17
	Me_3SiOH	21	42
degassed 403 K, 180 min	Me_3SiOSi	12	24
	$\text{Me}_2\text{Si}(\text{OH})\text{OSi}$	-5, -10	17
	Lewis adduct	41	10
	Me_3SiCl	27	46
	Me_3SiOH	21	
	Me_3SiOSi	13	
vapor 473 K, 120 min, degassed 30 min	$\text{Me}_2\text{Si}(\text{OH})\text{OSi}$	-9	28
	$\text{MeSi}(\text{OH})(\text{OSi})_2$	-50	16
	Me_3SiOSi	7	37
	$\text{Me}_2\text{Si}(\text{OH})(\text{OSi})$	-11, -14	33
	$\text{MeSi}(\text{OH})(\text{OSi})_2$	-53	15
	$\text{MeSi}(\text{OSi})_3$	-59	15
NaY			
vapor 295 K, 120 min, degassed 30 min	Lewis adduct	38	77
	Me_3SiOH	18	14
	Me_3SiOSi	6	9

The reactions of the trimethoxysilane can be understood in terms of protolysis and condensation with the framework, as summarized in Scheme III. Reaction of the methoxy groups with zeolite protons causes breaking of the oxygen-silicon bond to give framework bonded siloxanes and methanol (Scheme III). The methanol hydroxyls are detected in corresponding IR spectra (Figure 4B). As with Me_3SiOMe , the chemisorption of the trimethoxysilane in acid zeolite proves to be irreversible: Supercage hydroxyls are not restored at higher degassing temperatures (Figure 4C,D), indicating that stoichiometric substitution reactions take place, rather than acid-catalyzed hydrolysis of the adsorbed silane.

Trimethylchlorosilane. Saturation of HY with vapor of Me_3SiCl at 295 K generates four new silicon species in the ^{29}Si NMR of the zeolite (Table IV, Figure 5A). The component at 21 ppm (42%) is assigned to Me_3SiOH (predicted 17 ppm). The resonance at 12 ppm (24%) is assigned to trimethylsiloxy groups and the broad resonance between -5 and -10 ppm to dimethylsiloxy groups, both bonded to the zeolite.

The sample also exhibits a peak at +40 ppm (17%). In addition to Me_3SiCl -treated zeolites, several other of the materials studied here exhibit a peak at about +40 ppm.

Several observations regarding this resonance are summarized below.

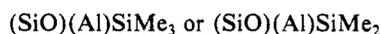
(a) Resonances with comparable chemical shift are observed after exposure to Me_3SiH (41 ppm), $(\text{Me}_3\text{Si})_2\text{NH}$ (41 ppm), Me_3SiOMe (31 ppm), and Me_3SiCl (40 ppm) but are not formed from $\text{MeSi}(\text{OMe})_3$. This suggests that the species is a *substituted trimethylsilyl group*.

(b) ^{29}Si chemical shift correlations reported earlier²⁸ allow us to exclude the presence of a π -bonding, electronegative ligand on Si, as this would move the chemical shift upfield into the range encompassed by the species listed in Table I. In fact, no tetravalent silanes or siloxanes having H, Cl, Me, or OMe ligands exhibit shifts this far to low field.

(c) These same chemical shift correlations predict that a ligand which has higher electronegativity than Me and which is capable of only σ -bonding, and not π -bonding interactions with Si, will produce a downfield shift like that observed. Indeed, trimethylsilyl ligands on metals are known to exhibit chemical shifts above +35 ppm (e.g., $(\text{Me}_3\text{Si})_2\text{Hg}$, +64 ppm).

These observations do not lead to a definite assignment for this resonance, but two possibilities are listed below.

(1) The first is a silane-Lewis acid adduct, with a direct Si-metal bond, like



This proposed species is also consistent with a proton-consuming reaction, which is indicated by the loss of intensity of zeolite hydroxyls in the IR spectra.

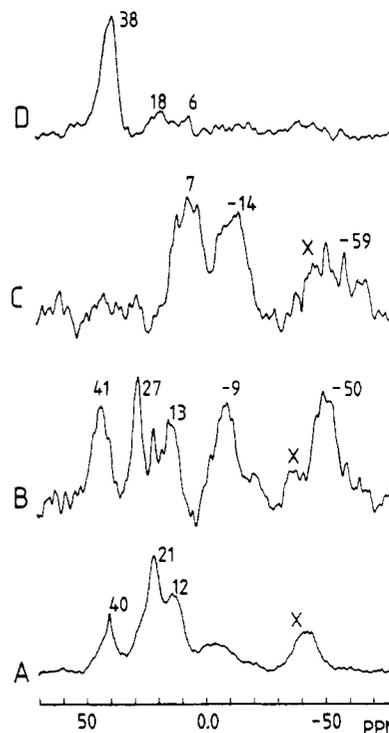
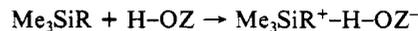


Figure 5. ^{29}Si CP-MAS NMR spectra of trimethylchlorosilane chemisorbed on dehydrated HY zeolite. X denotes spinning sidebands from the zeolite framework resonances. (A) Equilibrated for 120 min at 295 K, degassed for 30 min (1.2/SC); (B) degassed for 180 min at 403 K (<0.2/SC); (C) equilibrated for 120 min at 473 K, degassed for 30 min (2.1/SC); and (D) dehydrated NaY zeolite, equilibrated with the silane at 295 K for 120 min, degassed for 30 min (2.8/SC).

(2) The second is reaction with acidic zeolite hydroxyls to form a strongly hydrogen-bonded silane, with partial positive charge on Si, as



Even though this species cannot be identified unambiguously in the present study, the authors favor the first alternative because the product is independent of the reactive group (Cl, OMe, etc.) at the silane.

If the $\text{Me}_3\text{SiCl}/\text{HY}$ adduct is degassed at 403 K, higher substituted siloxane species (-9 ppm, $\text{Me}_2\text{Si}(\text{OH})\text{OSi}$; -50 ppm, $\text{MeSi}(\text{OH})(\text{OSi})_2$) are observed (Figure 5B). A more severe treatment of the zeolite with silane vapor at 473 K gives rise to a different product pattern (Figure 5C): The higher partial pressure of the starting material causes a high concentration of the framework-anchored $\text{Me}_3\text{Si}(\text{OSi})$ at about 7 ppm (37%). Trisubstituted siloxanes are generated in substantial amounts under the high partial pressure conditions; species with resonances between -51 and -59 ppm (e.g., $\text{MeSi}(\text{OH})(\text{OSi})_2$) account for 30% of the silicon loading.

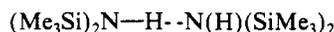
Chemisorption experiments with Me_3SiCl in non-acidic NaY support provide further evidence as to the nature of the acid reaction products (Figure 5D): The predominant species is a resonance at 38 ppm (77%), accompanied by smaller amounts of Me_3SiOH at 18 ppm and $\text{Me}_3\text{Si}(\text{OSi})$ at 6 ppm. Since the chemical shift of Me_3SiCl is 30 ppm, the peak at 38 ppm is unlikely to represent the unreacted starting material. This species is proposed to be due to an association between the zeolite sodium ions and the silane.

If a dehydrated wafer of HY is equilibrated with Me_3SiCl at 295 K in the IR cell, a consumption of the major fraction of supercage hydroxyls is observed as with the other silanes under study (Figure 6B). A major difference to the former systems is the high-frequency band between 3500 and 3100 cm^{-1} , indicating hydroxyl bridges of moderate strength. This band can be un-

of dehydrated HY (Figure 10A) is saturated with the silazane, almost no interaction with the zeolitic hydroxyls at 3640 and 3540 cm^{-1} , except the terminal SiOH at 3745 cm^{-1} , is detected (Figure 10B). This is in strong contrast to all other silanes studied. A new high-frequency band at 3400 cm^{-1} is assigned to the $\nu(\text{N-H})$ and the broad bands at 1500–1400 cm^{-1} to the corresponding N–H bending vibrations. A very broad absorption between 3400 and 2400 cm^{-1} is due to intermolecular N–H hydrogen bridges. Hydroxyl bridges can be excluded since the zeolite hydroxyls remain unaffected by the chemisorption.

If the zeolite wafer is saturated with silazane again at 403 K, both zeolite hydroxyl bands now are almost completely destroyed (Figure 10C), indicating that sodalite protons have traveled into the supercage. The $\nu(\text{N-H})$ band at 3400 cm^{-1} is significantly diminished, due to reaction with the zeolite hydroxyls. A strong broad band at 1430 cm^{-1} is assigned to ammonium ions formed upon protonation by the acid zeolite. The $\delta(\text{C-H})$ band at 1260 cm^{-1} (due to CH_3Si) grows significantly upon vapor treatment at 403 K. This provides evidence for the anchoring reaction as indicated by the NMR results. Silazane treatment at 473 K pronounces the reactions observed at 403 K (Figure 10D).

The reactivity of $(\text{Me}_3\text{Si})_2\text{NH}$ in acid Y zeolite is lower than that of methoxy- and chlorosilanes. This is shown in the in situ IR by the intact zeolite hydroxyls after adsorption at 295 K. Strong intermolecular N–H bridges characterize the intrazeolite environment of the silazane:



At elevated temperatures, the zeolite hydroxyls do react almost to completion with the silazane, generating several protolysis products. NMR and IR data are consistent with the anchoring reactions outlined in Scheme V.

Conclusion

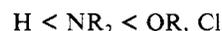
The reactivity of functionalized silanes with the bridged hydroxyls within zeolitic pore systems has been investigated employing a combination of ^{29}Si solid-state NMR and in situ IR techniques.

Due to their extreme acidity, the bridged zeolitic hydroxyls react in a fashion strikingly different from the behavior of terminal hydroxyls found at the surface of amorphous oxides. At moderate temperature, functional groups at the silane like OR, Cl, NR_2 ,

or H are lost to form bridges to the zeolite framework. The reaction does not stop at this point, however. Si–C bonds are broken at elevated temperature, splitting off alkyl groups, and more highly substituted siloxane species are anchored to the framework.

The incorporation of silyl groups into the zeolite lattice could be considered as a model for early steps during the more severe lattice rearrangements observed upon reacting SiCl_4 with an acid zeolite. In the latter case, framework aluminum atoms are substituted by silicon.

On the basis of the number of products and the reversibility of silane chemisorption, the reactivity of functional groups at Si with bridged zeolitic hydroxyls increases in the sequence



If $\text{Me}_3\text{Si-H}$, $-\text{NR}_2$ or $-\text{Cl}$ is reacted with the acidic zeolite, a product with a very unusual ^{29}Si chemical shift at about +40 ppm is observed. Although no definitive assignment for this species can be given at this time, it is clear that an electronegative σ -bonding ligand must be bonded to Si. The observations indicate either a strongly hydrogen-bonded silane with partial positive charge on the Si or a silane–Lewis acid adduct, incorporated into the framework with a direct Si–metal bond.

Despite the complexity of the reactions considered, it is clear that bridged hydroxyls on solid surfaces are far more reactive than terminal hydroxyls.

The results of this study provide the basis for a systematic approach to modify and “functionalize” the internal surface of zeolitic cage systems. The work has been extended to reactive phosphorus compounds,³⁶ and related results will be reported elsewhere.

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Registry No. Me_3SiOMe , 1825-61-2; MeSi(OMe)_3 , 1185-55-3; Me_3SiCl , 75-77-4; Me_3SiH , 993-07-7; $(\text{Me}_3\text{Si})_2\text{NH}$, 999-97-3.

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